

Chemical Vapor Deposition of Niobium Coating on Zirconia Microspheres

Christine T. Snyder

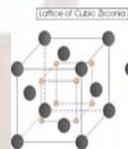
L. E. Putty, T. C. Carter,^a A. S. Hebden, B. W. Campbell,^b L. Leibowitz, and S. M. McDevitt
 Chemical Engineering Division, University of Florida,^a and Iowa State University^b

Introduction

- As part of the Department of Energy's Advanced Fuel Cycle Initiative, a coating method for eventual use in fabricating actinide-burning transmuter fuel was developed.
- Chemical vapor deposition (CVD) was the method chosen to coat zirconium oxide non-radioactive microspheres in method development experiments. CVD uses a vaporized chemical compound, or precursor, to coat a substrate.

Precursor

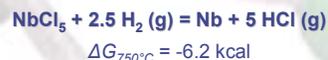
Niobium pentachloride
 Solid at room temperature
 Melting point is 205°C



Substrate

Zirconium oxide
 100-μm spheres

Chemistry



The CVD System



Fluidizing the Microspheres



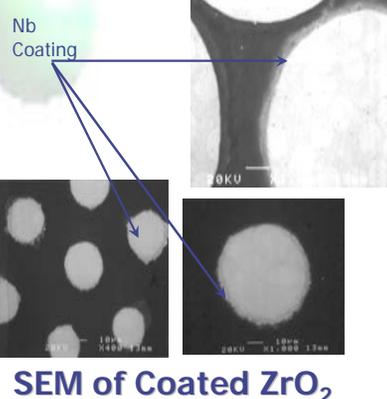
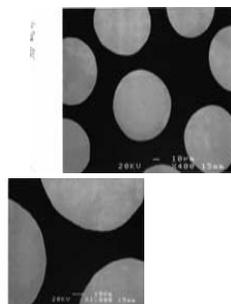
Temperature Limitation

- The coating process had a temperature constraint of ~ 1000°C because americium and americium oxide volatilize at temperatures commonly used for fabrication of nuclear fuel.
- Initial process development activities were carried out using zirconia microspheres as a surrogate for the actinide oxides.

Conditions

Substrate – Zirconium oxide 100-μm spheres
 Substrate Temperature - 750-800°C
 Fluidizing gas – Helium 4% hydrogen at flowrate of 100mL/min
 Precursor – Niobium pentachloride
 Precursor introduction gas – Helium
 Chemical Reaction - $\text{NbCl}_5 + 2.5 \text{H}_2 = \text{Nb}(\text{s}) + 5 \text{HCl}$
 Reactor Vessel Composition - Quartz

SEM of Uncoated ZrO₂



Conclusions

Zirconium oxide microspheres were successfully coated with niobium. The integrity of the coating was confirmed by EDS.

